

Tohoku Univ. Technology

Single-crystal aluminum nitride seed crystal

Able to create AIN seed crystal at low temperature, easy temperature control and fast growth rate

Overview

Deep ultraviolet light emitting device (DUV-LED) is fabricated from AlGaN-based nitride semiconductor. The substrate material for the AlGaN-based DUV-LED is required to have high lattice matching with AlGaN, wider band gap than AlGaN and high thermal conductivity. Aluminum nitride (AIN) is attracting attention since it satisfies those conditions.

The sublimation method is a conventional method for producing AIN single crystal, but the cost is high because of high temperature requirement, and temperature control is also difficult.

Using this technology, single-crystal AIN seed crystal can be created at a relatively high speed under low-temperature and easy temperature control conditions.



Possible to create highly oriented single-crystal AIN seed crystal



←Cross-sectional image of AIN seed crystal

Confirmation of extremely highly oriented single crystal from the pole figure

1 AIN seed crystal ↓

1 mm

Product Application

- □ AIN crystal as AIGaN-based nitride semiconductor substrate
- In particular, the creation of seed crystal as a starting point for the growth of AIN on AIN substrate

IP Data

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Related Works

[1] AMEI Chiaki, TOKUCHI Yuki, ADACHI Masayoshi, OTSUKA Makoto, FUKUYAMA Hiroyuki, The Japan Institute of Metals and Materials 2022 Spring lecture conference, 77.

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